

Notice of References Cited	Application/Control No. 10/576,724		Applicant(s)/Patent Under Reexamination LABROUSSE ET AL.	
	Examiner DIANA J. LIAO		Art Unit 1793	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-6,576,344	06-2003	Doushita et al.	428/426
*	B	US-5,225,031	07-1993	McKee et al.	428/471
*	C	US-6,465,042	10-2002	Saitoh et al.	427/255.19
	D	US-			
	E	US-			
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	O					
	P					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Wenjie Zhang, Ying Li, Shenglong Zhu, Fuhui Wang, "Surface modification of TiO2 film by iron doping using reactive magnetron sputtering" Chemical Physics Letters 373 (2003), pp. 333-337.
	V	S.K. Zheng, T.M. Wang, C. Wang, G. Xiang, "Photocatalytic activity study of TiO2 thin films with and without Fe ion implantation" Nuclear Instruments and Methods in Physics Research B 187 (2002), pp. 479-484.
	W	P. Zeman, S. Takabayashi, "Nano-scaled photocatalytic TiO2 thin films prepared by magnetron sputtering" Thin Solid Films 433 (2003), pp. 57-62.
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.